



Korean Intellectual
Property Office

Design Policy and Strategy

in the Expansion of Global Economic Initiatives

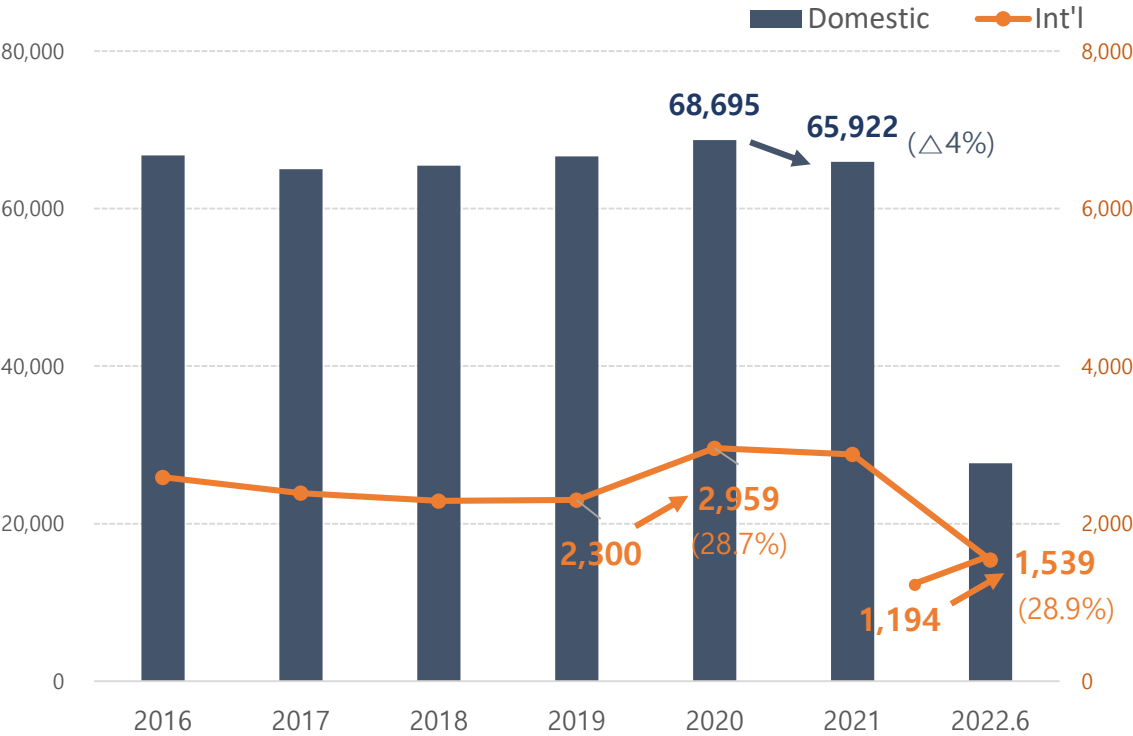
CHOI, Chul-Seung, Director

Design Examination Policy Division, KIPO

- **Current Status : Application, First office action pendency**
- **Strategic Use of Industrial Design system in Korea**

Current Status - Application

KR Design Applications ('16~'22.6)



■ **65,922** domestic applications in '21

■ **Increase** in Int'l design (Hague)

- '20 : **28.7%** over '19

- '22.6 : **28.9%** over '21.6

Current Status – First Office Action Pendency

■ Hybrid Examination System

: Partial Examined design (class 1,2,3,5,9,11 or 19)

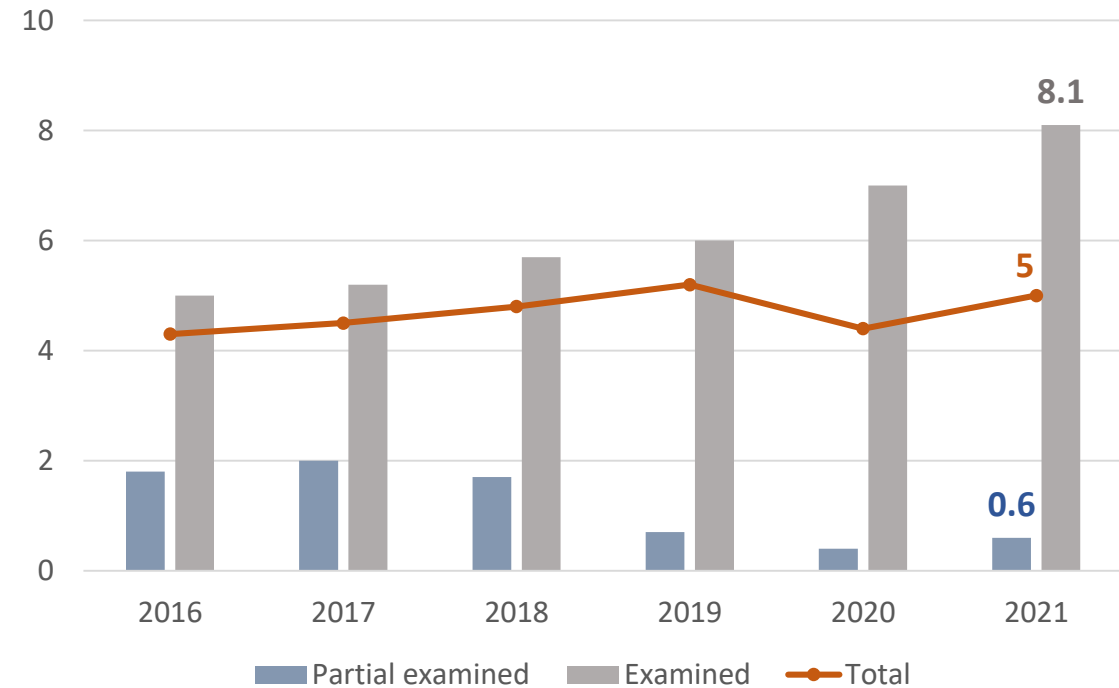
: Examined design (except the above)

■ **0.6 months** for partial examined design

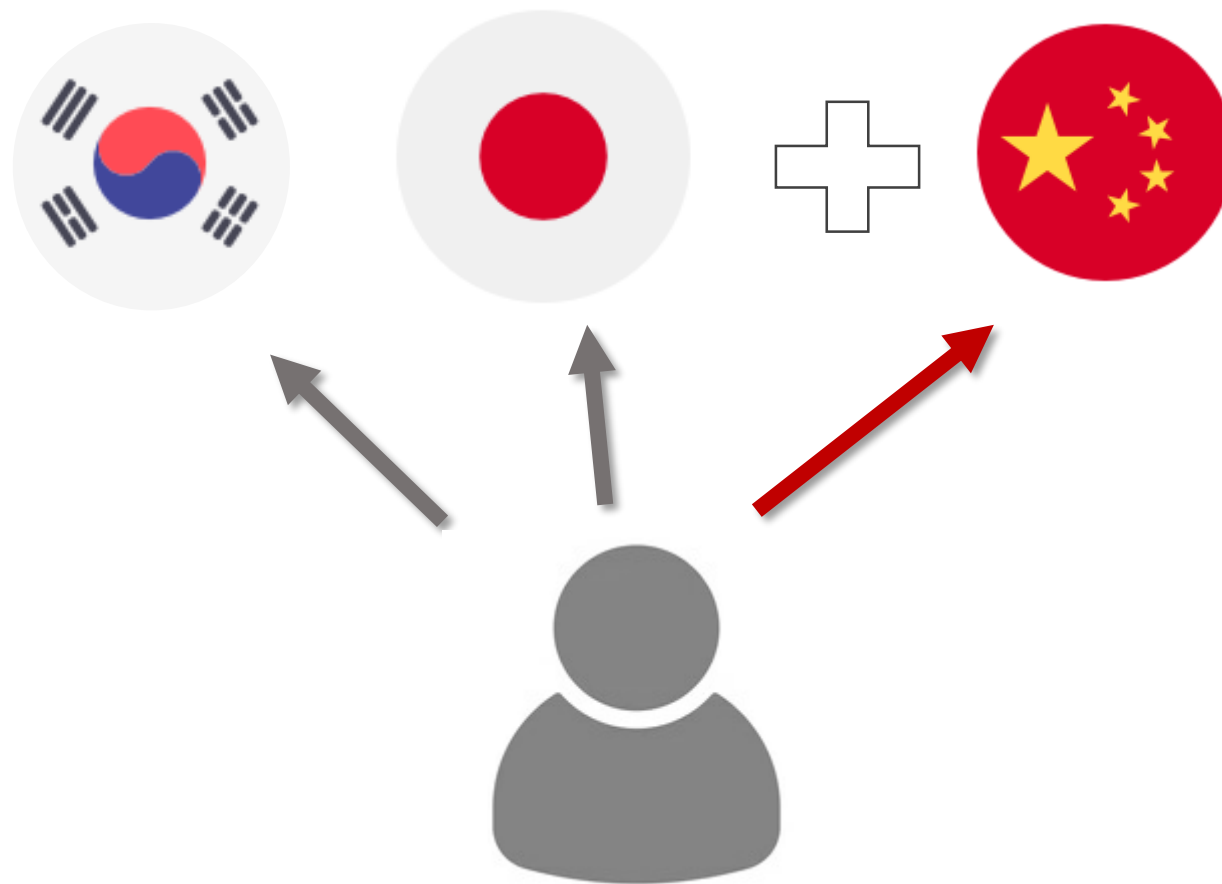
8.1 months for examined design

→ **5.0 months** for First OA in general

First Office Action Pendency (domestic, months)

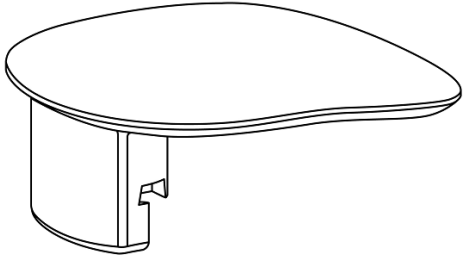
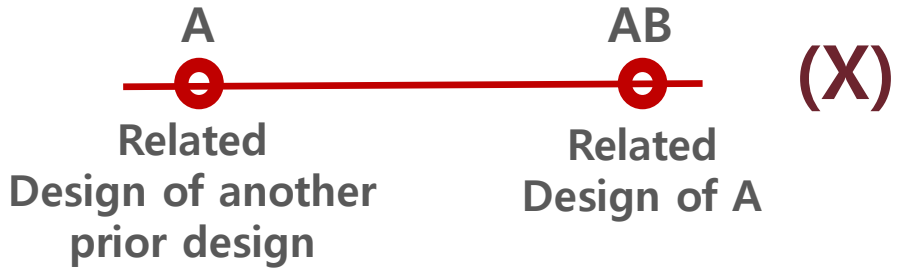
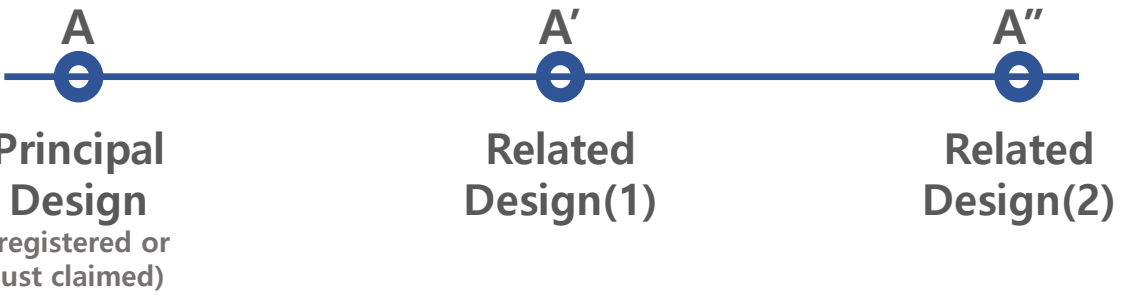


Strategic Use of ID System – for Hague Applicants

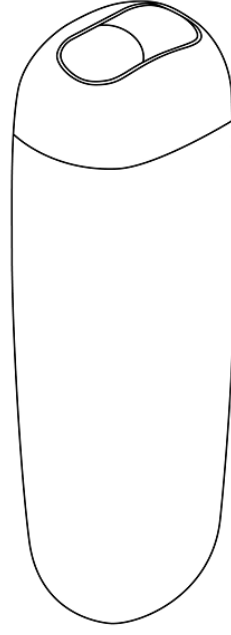
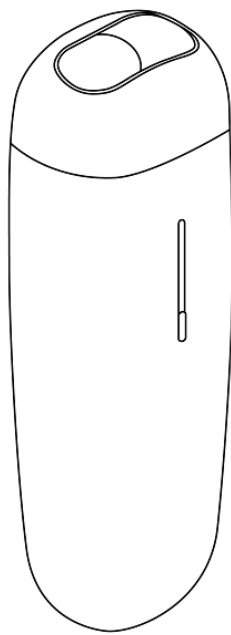


Strategic Use of ID System – related design

Only within 12 months



DM/211246



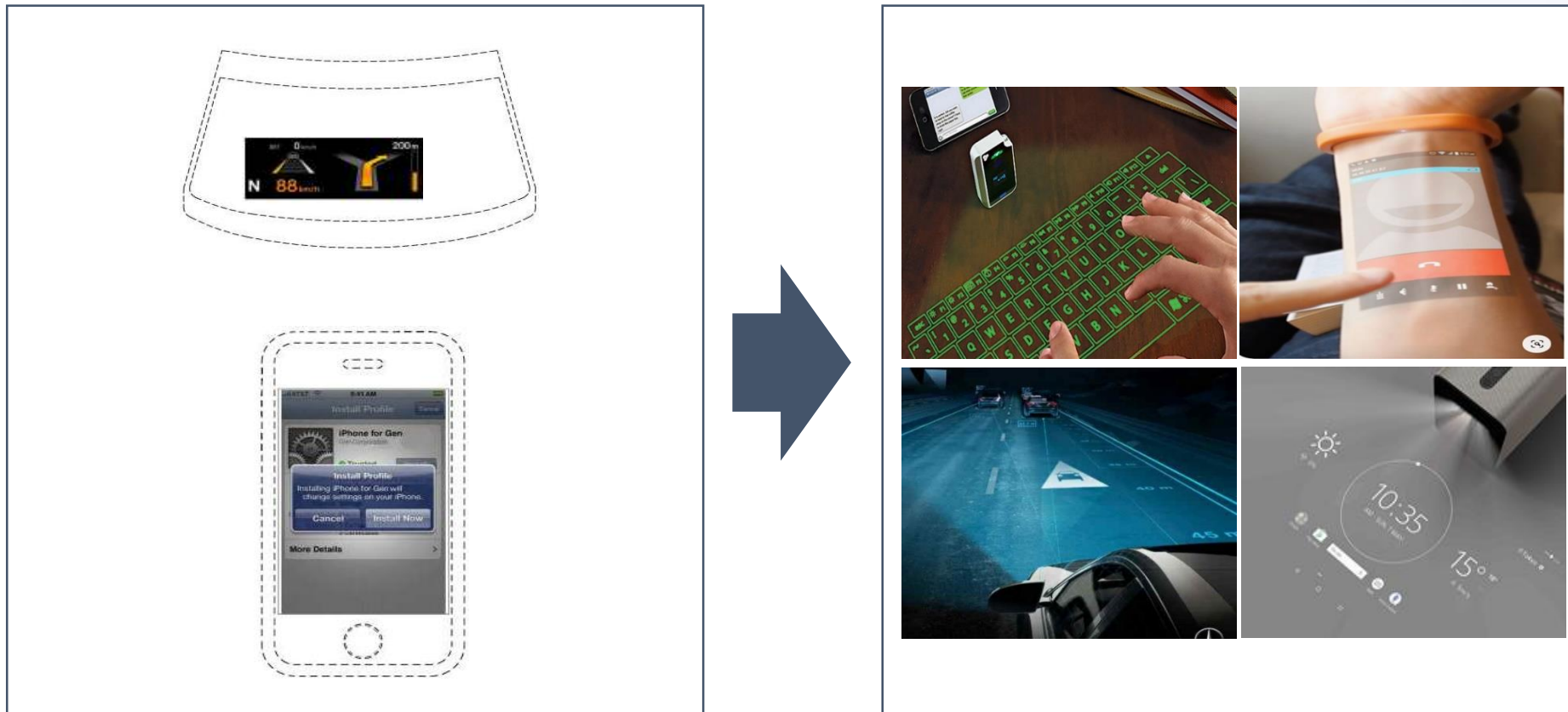
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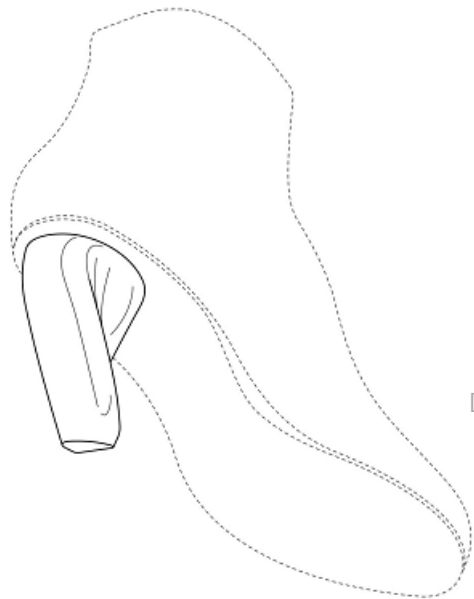
Strategic Use of ID System – graphic image design



- ✓ limited to those **used to operate the device** or **displayed as a result of the device performing its function**

Strategic Use of ID System – partial design

Indication of product



DM/216193

Shoe heel → Shoe

Drawing : broken lines, color, etc.



DM/097291

Strategic Use of ID System – exception to lack of novelty

Within **12 months** before filing an application

All kinds of publication

(**except for a design the application or registration** of which is **published** in the ROK or in a foreign country **under a treaty or an Act**)

1. When filing an application
2. Before a notification of refusal or design registration
3. When a person submits a written reply to an opposition to registration of a partially-examined design
4. When a person submits a written reply to a petition for a trial on the invalidation of design registration


DM/1/II (E)



ANNEX II

Supporting Document(s) Concerning a Declaration to the Exception to Lack of Novelty under Section 408(c)(ii) of the Administrative Instructions

IMPORTANT

1. This Annex can be used to submit documents in support of a declaration concerning exception to lack of novelty to the China National Intellectual Property Administration (CNIPA), the Japan Patent Office (JPO) and/or the Korean Intellectual Property Office (KIPO) (refer to form DM/1, item 15).
2. Please note that a declaration concerning exception to lack of novelty might affect the applicant's rights in other jurisdictions. It is the responsibility of the applicant to ensure that their rights are preserved.
3. For detailed information on the procedure when designating Japan, please visit the [JPO website](#).
4. This Annex must be submitted with form DM/1 at the time of filing; it cannot be submitted separately. 
5. Please number your pages.

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THANK YOU!

CHOI, Chul-Seung, Director

Design Examination Policy Division, KIPO